

# COVALENT METROLOGY

# Welcome



SURFACE CHARGE ON COLLOIDS, AND BEYOND: THE COMPLEMENTARITY OF SOLID- AND SOLUTION-STATE ZETA POTENTIAL MEASUREMENT

#### Thomas Luxbacher, PhD

Principal Scientist, Anton Paar

March 9, 2023 | 11am PT





#### COVALENT ACADEMY

Industrial Applications of Advanced Metrology Episode 34



Silicon Valley-based analytical labs and platform delivering quality data and expert analysis for advanced materials and device innovation

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Elemental / Chemical Composition Analysis	Particle Analysis	Material Property Characterization	Surface Spectroscopy Analysis
<ul> <li>EPMA</li> <li>GD-OES</li> <li>GC-MS</li> <li>ICP-MS and LA-ICP-MS</li> <li>Raman Microscopy &amp; Spectroscopy</li> <li>NMR (1D or 2D; solid / liquid)</li> </ul>	<ul> <li>Dynamic Light Scattering (DLS)</li> <li>Laser Diffraction Particle Size Analysis (PSA)</li> <li>Particle Zeta Potential</li> </ul>	<ul> <li>DSC</li> <li>DMA &amp; TMA</li> <li>Rheometry</li> <li>TGA</li> <li>Solid Surface Zeta Potential</li> <li>Porometry / Porosity</li> <li>Gas Adsorption</li> <li>Gas Pycnometry</li> <li>Foam Density</li> <li>Tap Density</li> </ul>	<ul> <li>Dynamic-SIMS</li> <li>ToF-SIMS (Static-SIMS)</li> <li>Ion Scattering Spectroscopy (ISS)</li> <li>Ultraviolet Photoelectron Spectroscopy (UPS)</li> <li>X-ray Photoelectron Spectroscopy (XPS)</li> </ul>

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#### **Covalent Partners**





#### Partnership with Anton Paar announced in May, 2020

- Established the Anton Paar Demonstration Facility in Covalent's Silicon Valley Laboratory with goals of
  - Expanding industry access
  - Developing new analytical applications
- Later expanded partnership to deliver industry-leading porous materials and powders analysis
- Partners continue to collaborate in advanced applications development

- Anton Paar Instruments at Covalent Metrology include:
  - SurPASS 3
  - Litesizer 500
  - MCR 702 Rheometer / DMA
  - STeP 6 Nanoindentation platform
  - Ultrapyc 5000 Micro
  - Autosorb iQ C-XR-XR with CryoSync accessory
  - Porometer 3G and DualAutoTap
  - NEW Upgraded Nova 800 BET (Gas Adsorption) Analyzer

#### **Other Covalent Partners** Rigaku HORIBA Thermo Fisher Scientific SCIENTIFIC TELEDYNE CETAC TECHNOLOGIES Evervwhere**vou**look' KEYENCE **Digital Surf PVA** TePla Woollam Instruments an Oxford Instruments company

Introducing

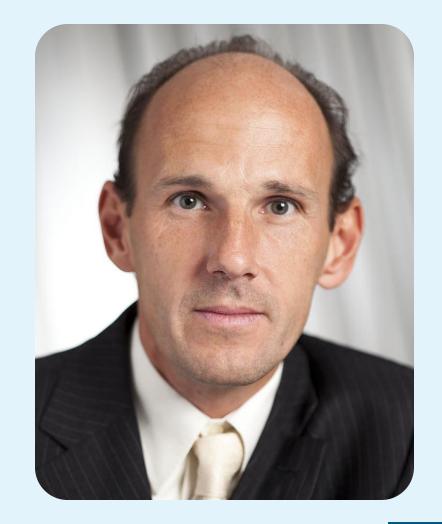


# **Dr. Thomas Luxbacher**

Principal Scientist, Anton Paar



- Thomas Luxbacher has been principal scientist for surface charge and zeta potential at Anton Paar since 2019.
- Prior to his present role, he was a product manager for surface zeta potential analyzers for more than 15 years.
- Before joining Anton Paar, Thomas gained experience in product development in the **semiconductor and automotive sectors.**
- He received his **MSc and PhD degrees in Physical Chemistry** from Graz University of Technology.



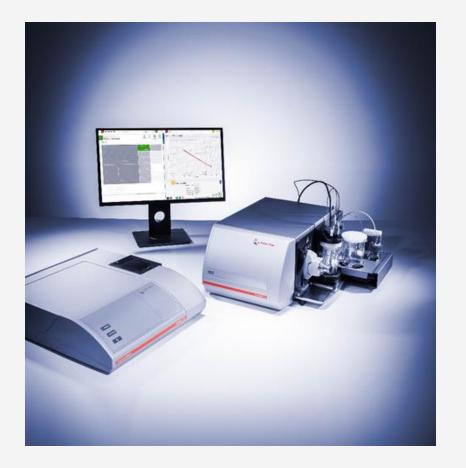


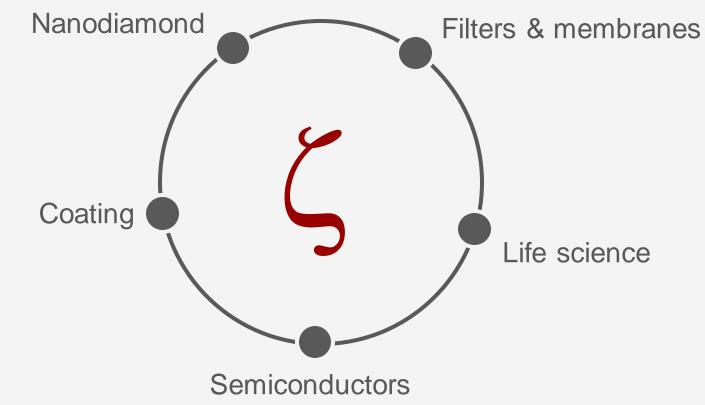
# Surface charge on colloids, and beyond: The complementarity of solid- and solution-state zeta potential measurement

Thomas Luxbacher, PhD Anton Paar GmbH, Graz, Austria



# What you will learn



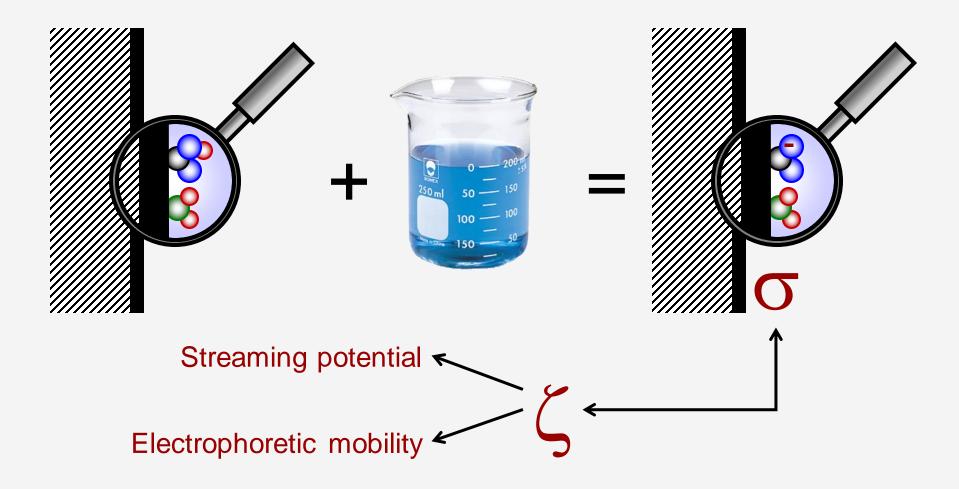




# Introduction to zeta potential

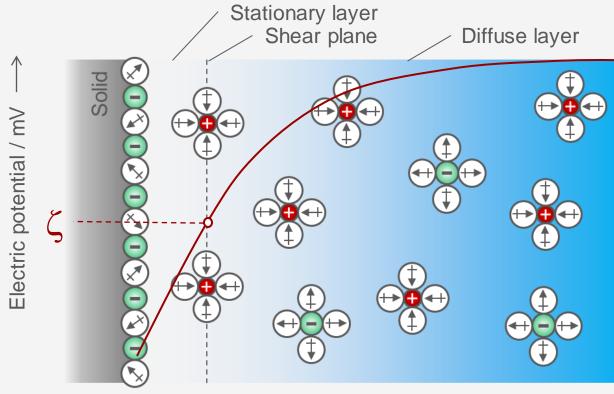


#### Zeta potential analysis





#### **Electric double layer**



Distance / nm  $\longrightarrow$ 

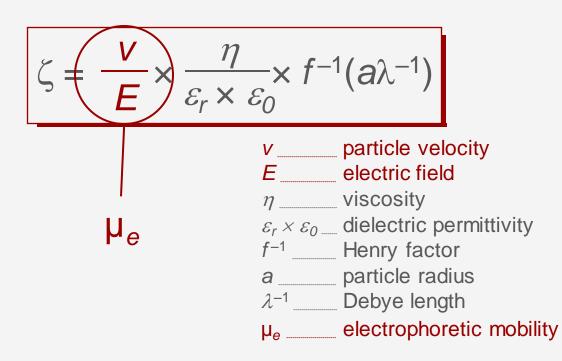


# **Electrophoretic mobility**

# **Electrophoretic mobility**

Electrophoretic light scattering (ELS)

 Electric field induces a collective movement of charged particles





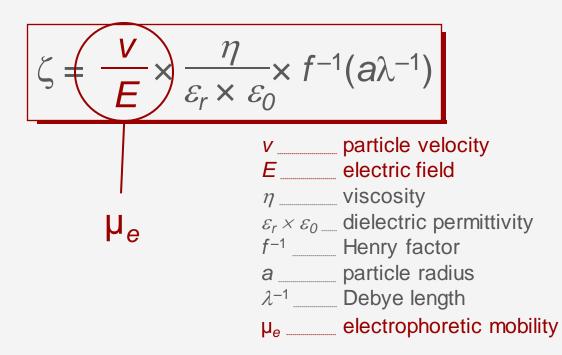




# **Electrophoretic mobility**

Electrophoretic light scattering (ELS)

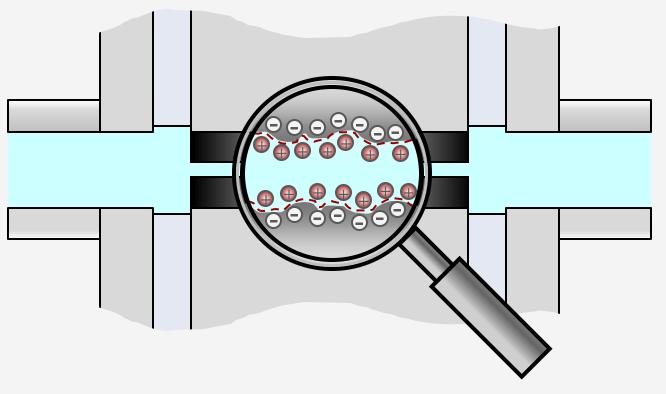
 Electric field induces a collective movement of charged particles





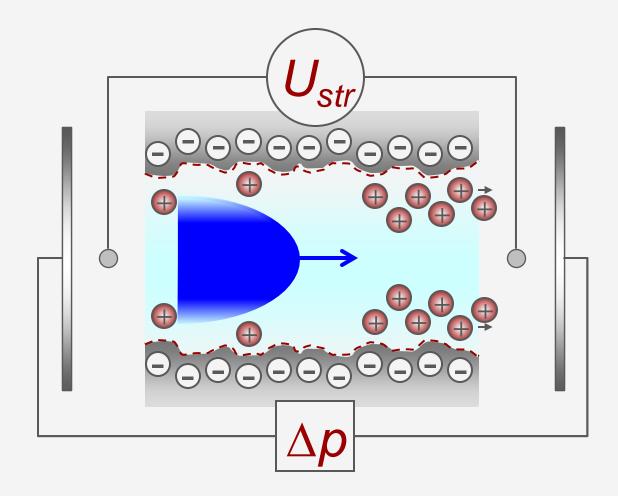






 Solid sample arranged to create a capillary channel

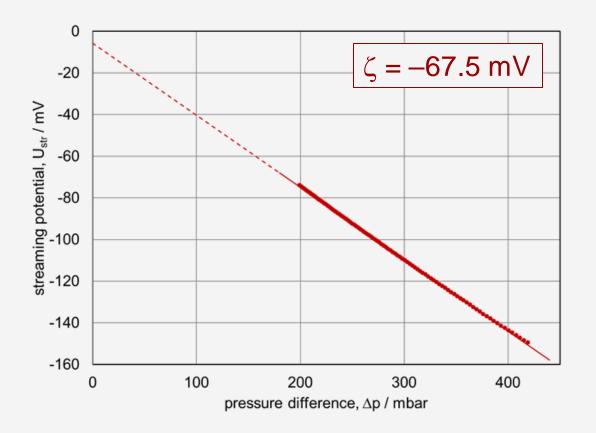




$$\zeta = \frac{dU_{str}}{d\Delta p} \times \frac{\eta}{\varepsilon_r \times \varepsilon_0} \times \kappa_B$$

U <sub>str</sub>	streaming potential
⊿p	pressure difference
η	viscosity
$\mathcal{E}_r \times \mathcal{E}_0$	dielectric permittivity
K <sub>B</sub>	electrolyte conductivity





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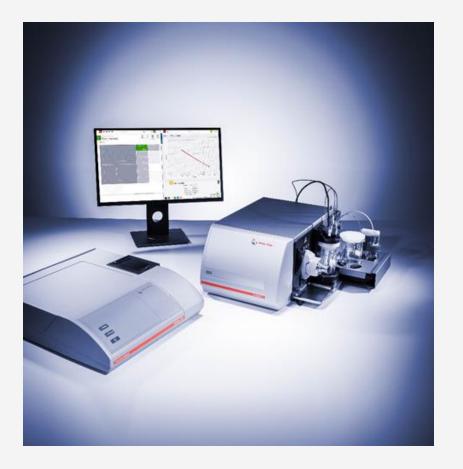


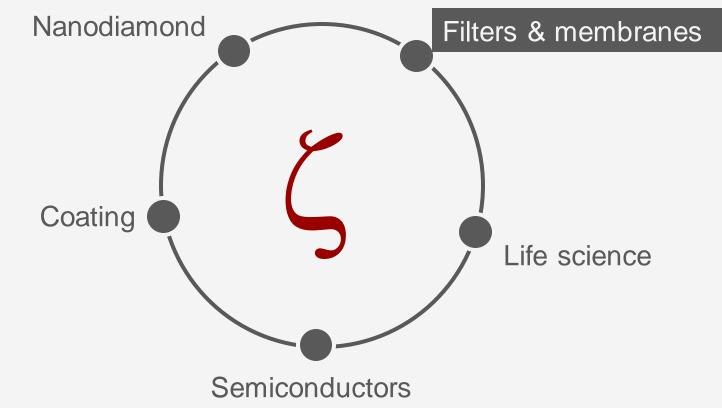
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### **Applications**



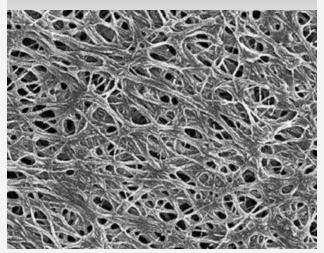




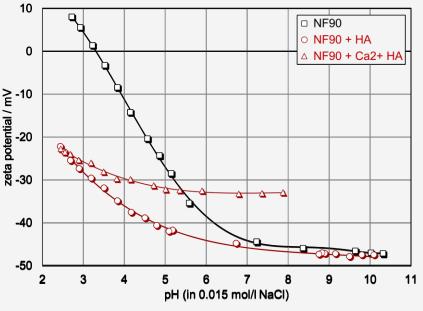
# **Filters and membranes**

—

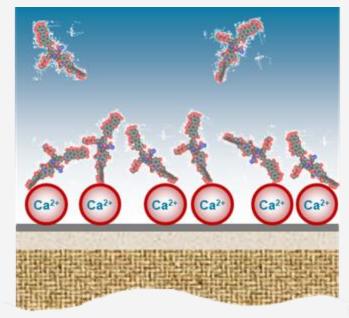
- Microfiltration
- Ultrafiltration
- Nanofiltration
- Reverse osmosis
- Forward osmosis



- Municipal and industrial wastewater
- Seawater desalination
- Separation and purification



- Solute rejection
- Membrane fouling
- Cleaning efficiency
- Surface modification

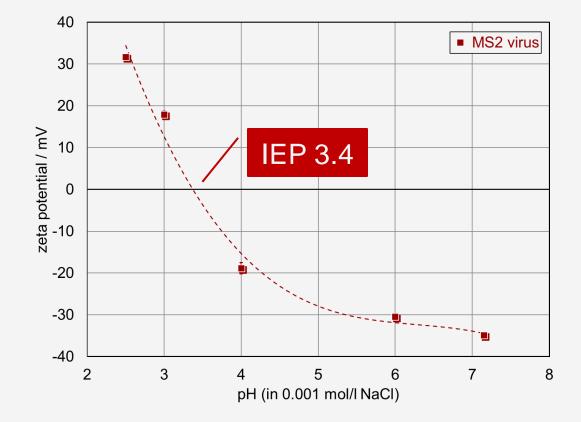


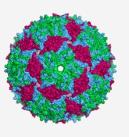
Imbrogno et al., J. Membr. Sci. 549 (2018) 474



MS2 bacteriophage

- Size (34 ± 2 nm), shape (icosahedral) and nucleic acid (ssRNA) similar to pathogenic viruses
- Resistant to chlorine disinfection and UV irradiation





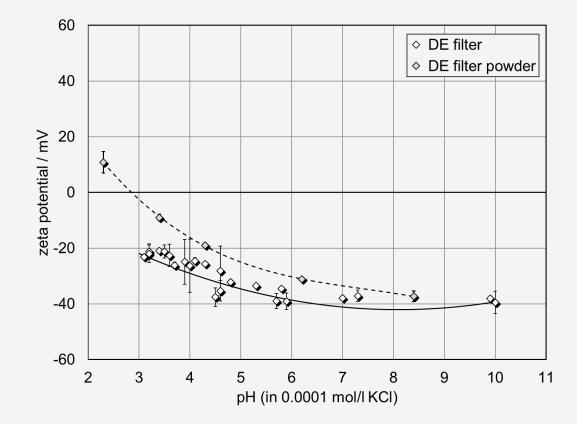


Diatomaceous earth filter

- Pore size 0.2 2 μm
- Specific surface area 2.2 m<sup>2</sup>/g
- Throughput 20 I/h/bar
- Bacteria retention 99.999 %

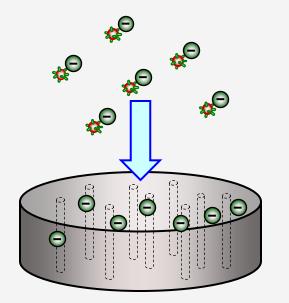


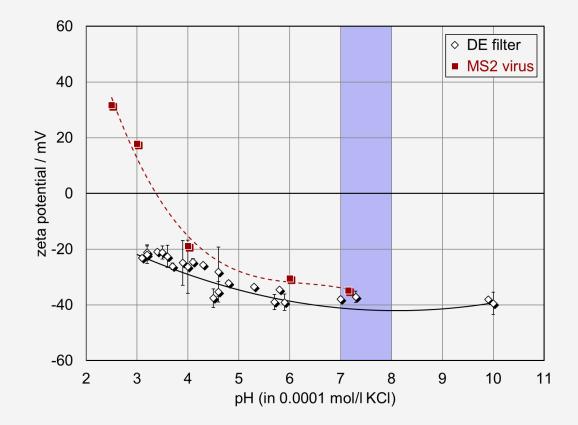
Wegmann et al., Water Res. 42 (2008) 1726





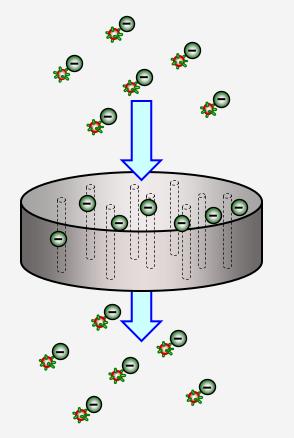
Diatomaceous earth filter

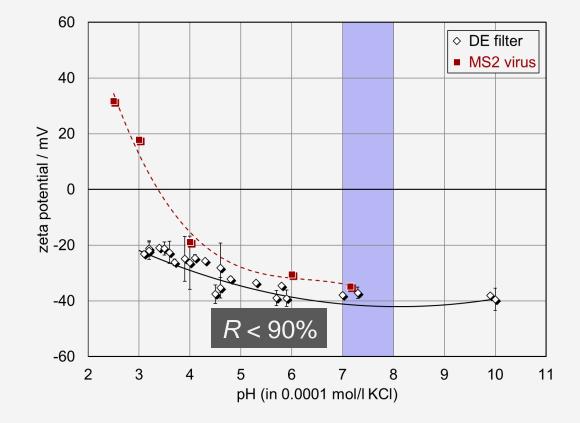






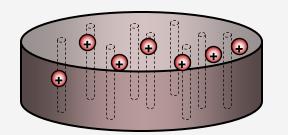
Diatomaceous earth filter

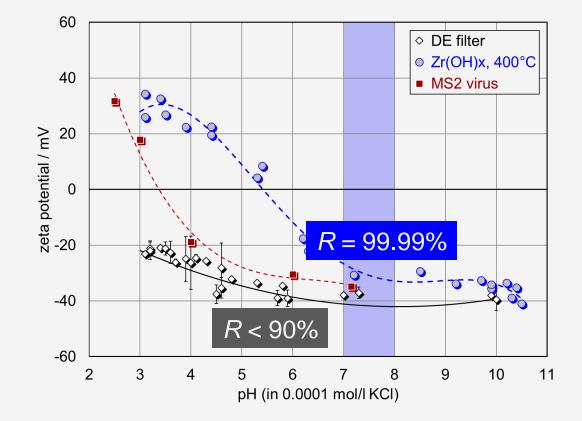






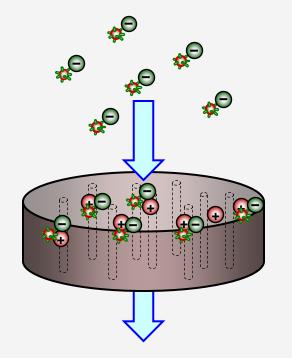
Modified filter

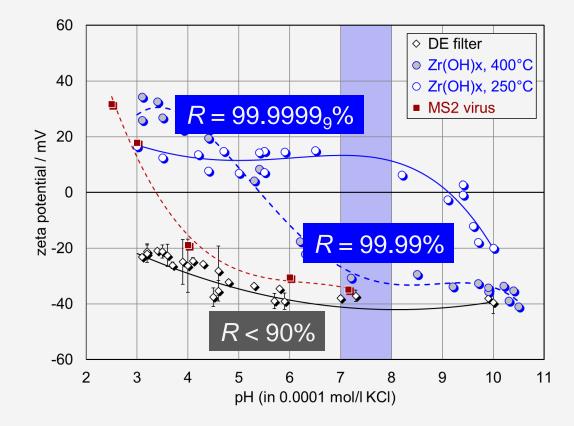






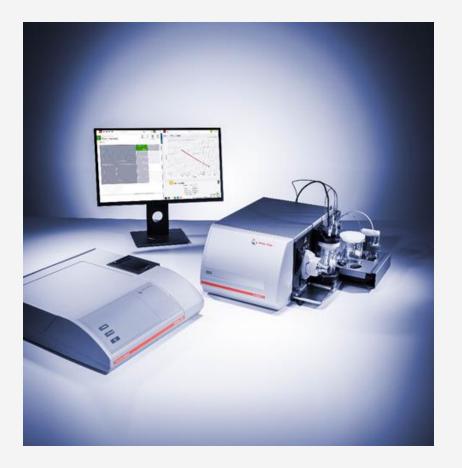
Modified filter

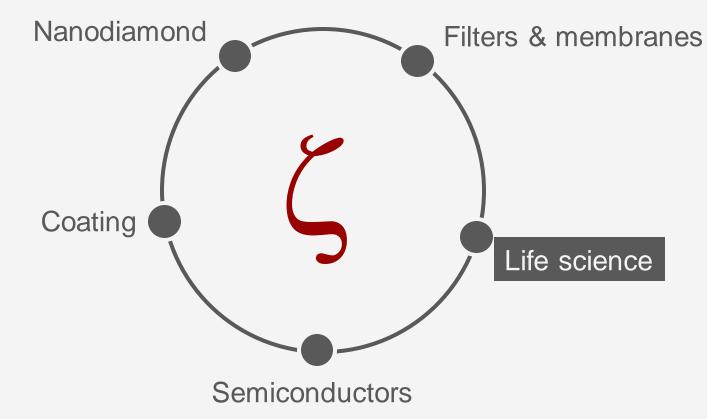






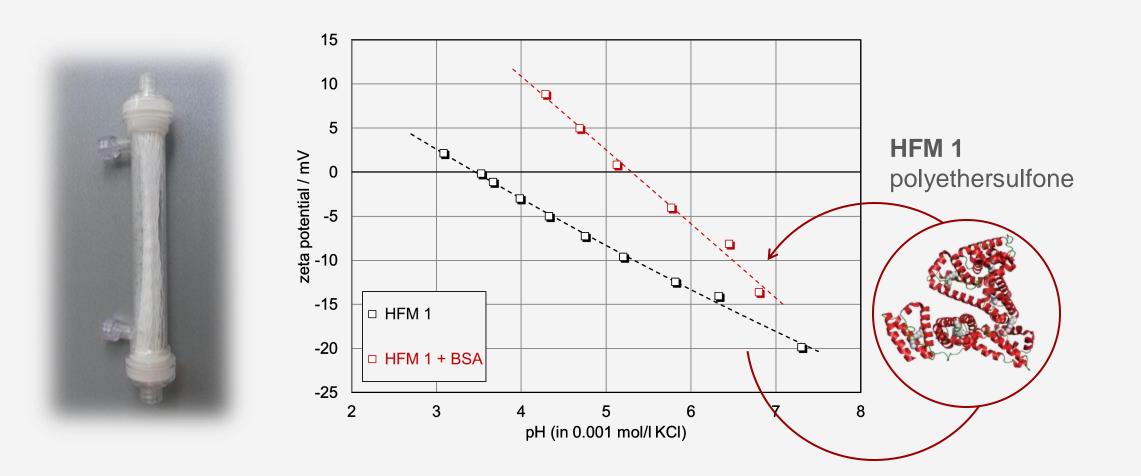
### **Applications**





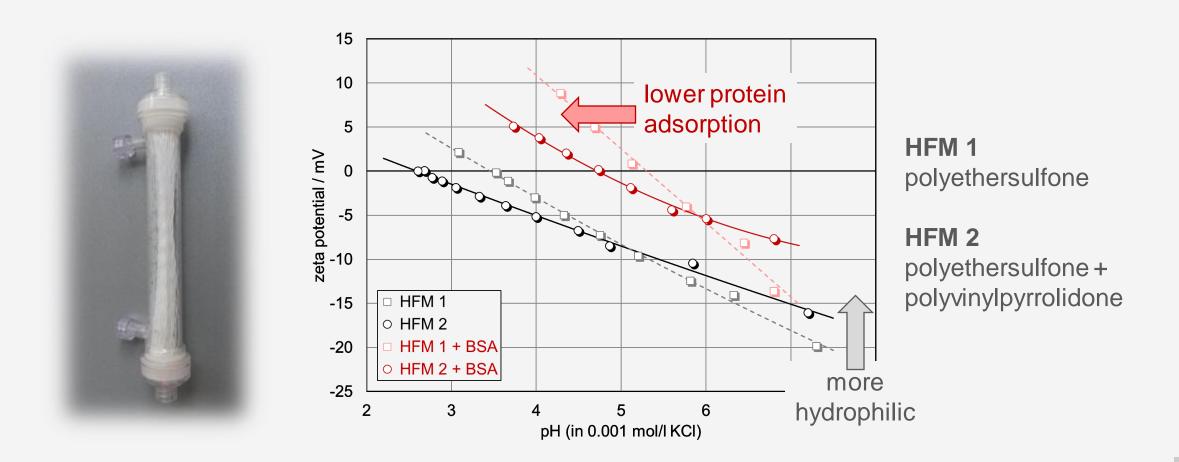


## **Dialysis membrane**



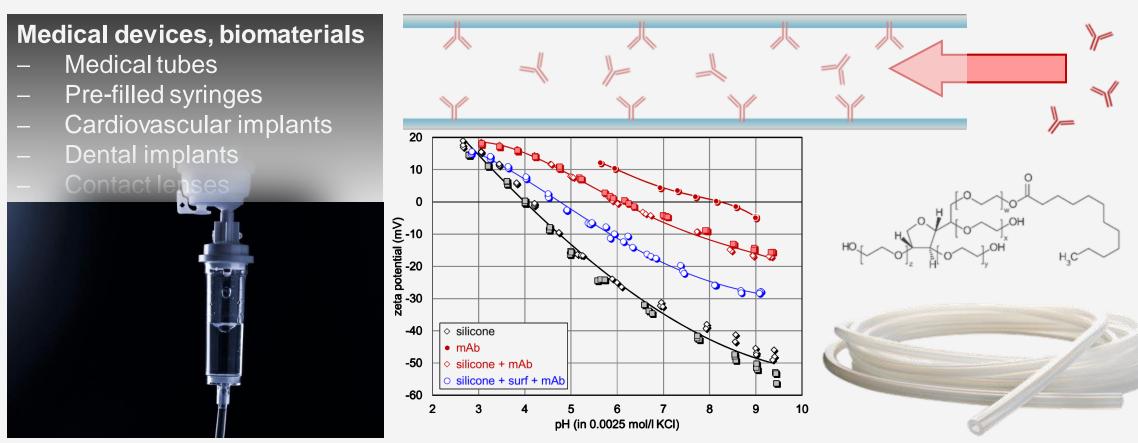


### **Dialysis membrane**





#### Life science

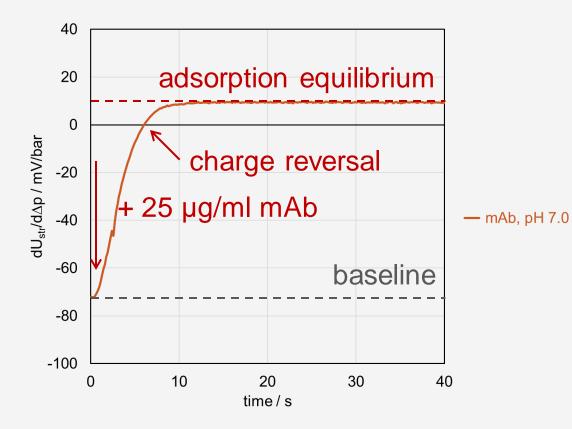


Deiringer et al., J. Pharm. Sci. 111 (2022) P1577



# **Dynamic streaming potential**

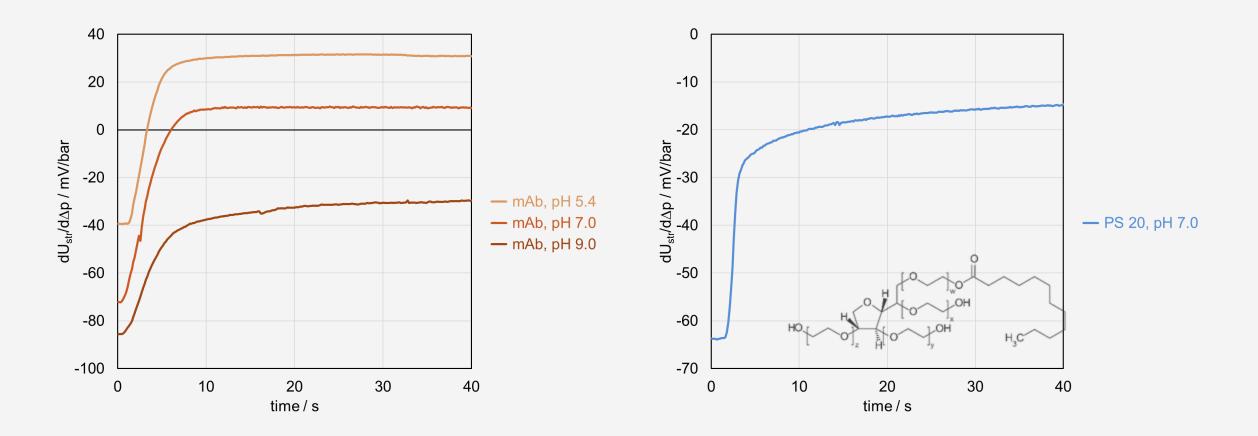
Adsorption kinetics





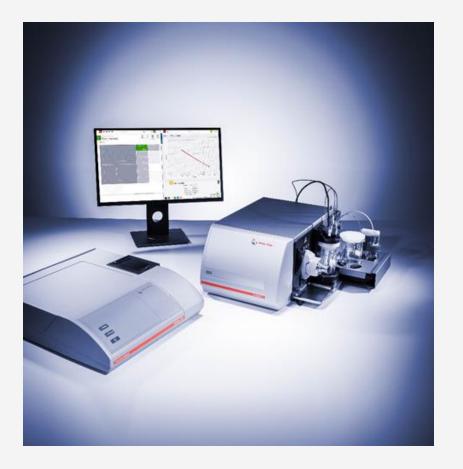
# **Dynamic streaming potential**

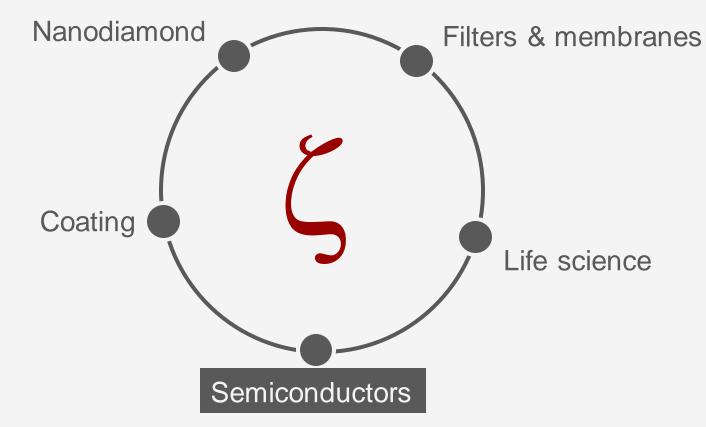
Adsorption kinetics





### **Applications**

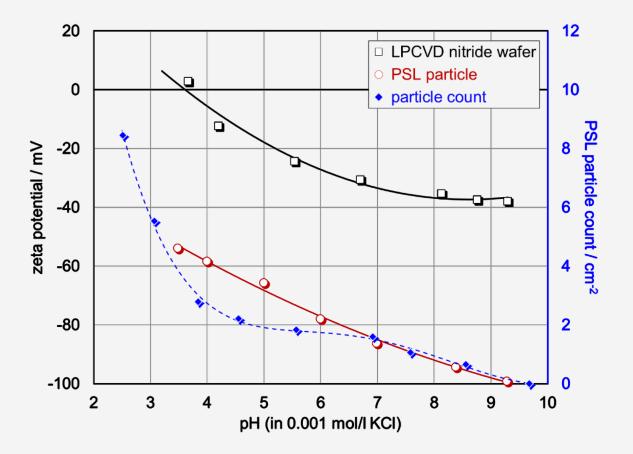






# **Wafer-particle interaction**

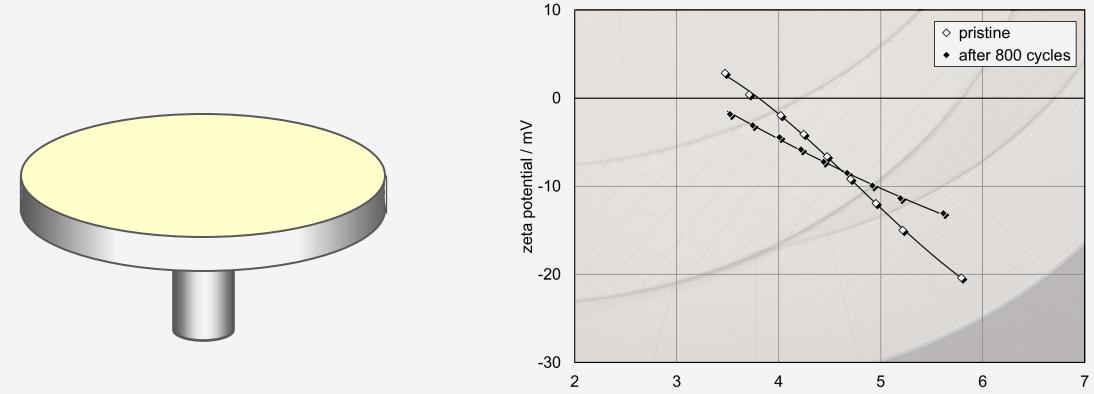
- Electrostatic force
   determines wafer-particle
   interaction in an aqueous
   environment
- Important for CMP process





# Wafer polishing process

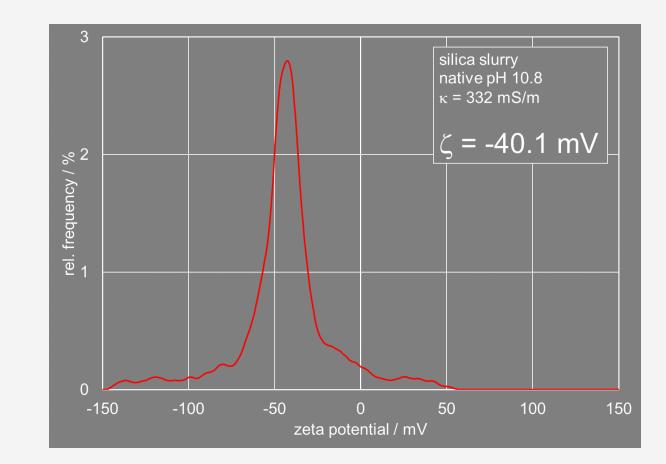
Polishing pad



pH (in 0.001 mol/l KCl)



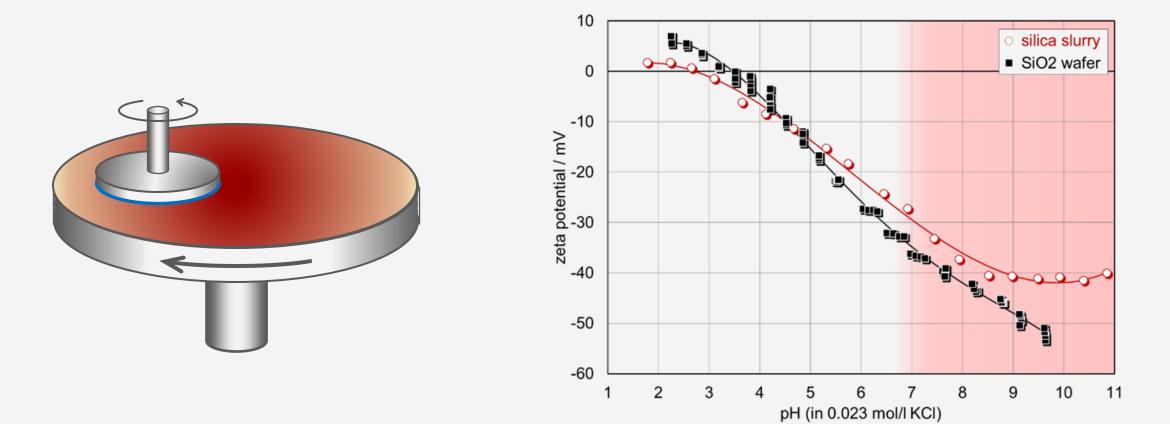
## Wafer polishing process CMP slurry





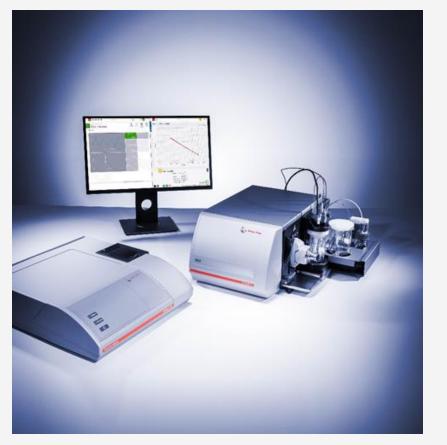
## Wafer polishing process

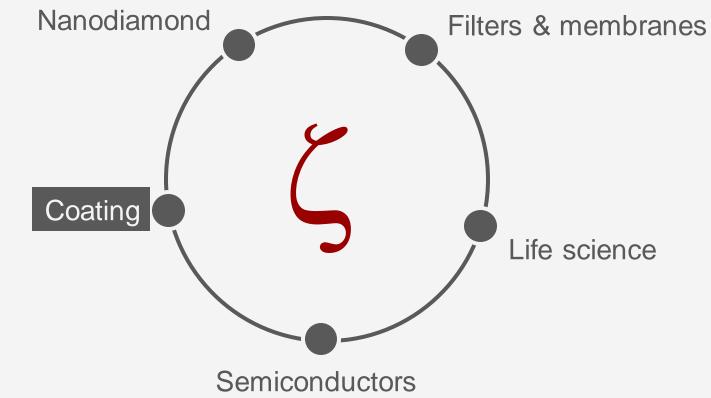
Wafer surface





## **Applications**

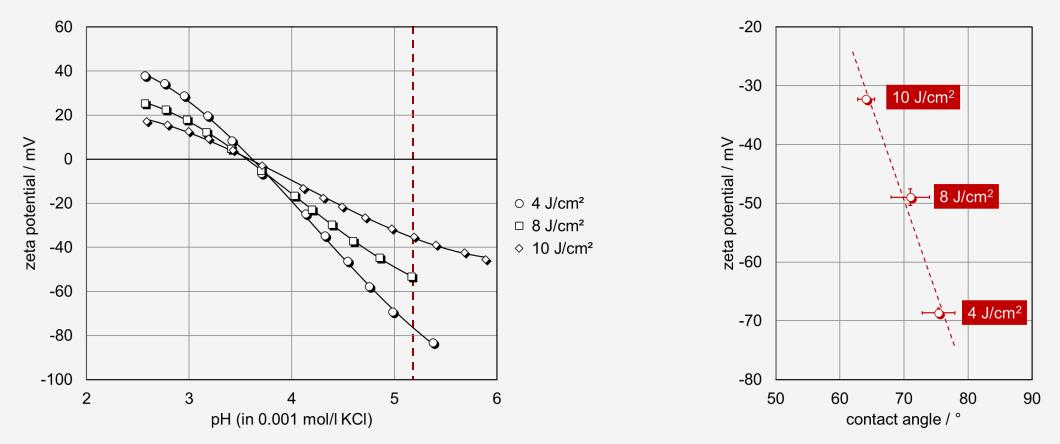






## **Thin-film coating**

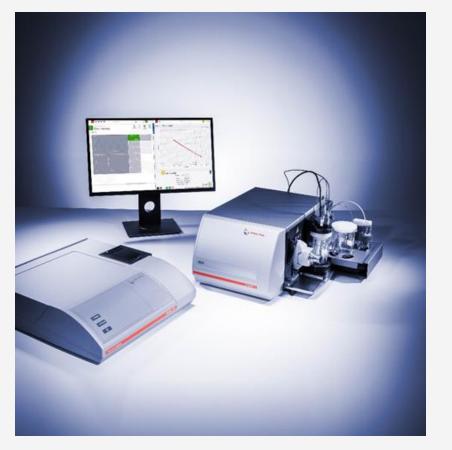
DLC diamond-like Carbon

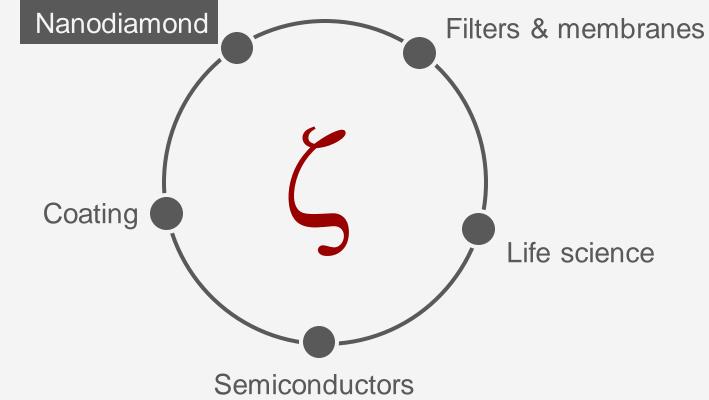


Jelinek et al., Mat. Sci. Eng. B 169 (2010) 89; Jelinek et al., Appl. Phys. A 101 (2010) 579



## **Applications**

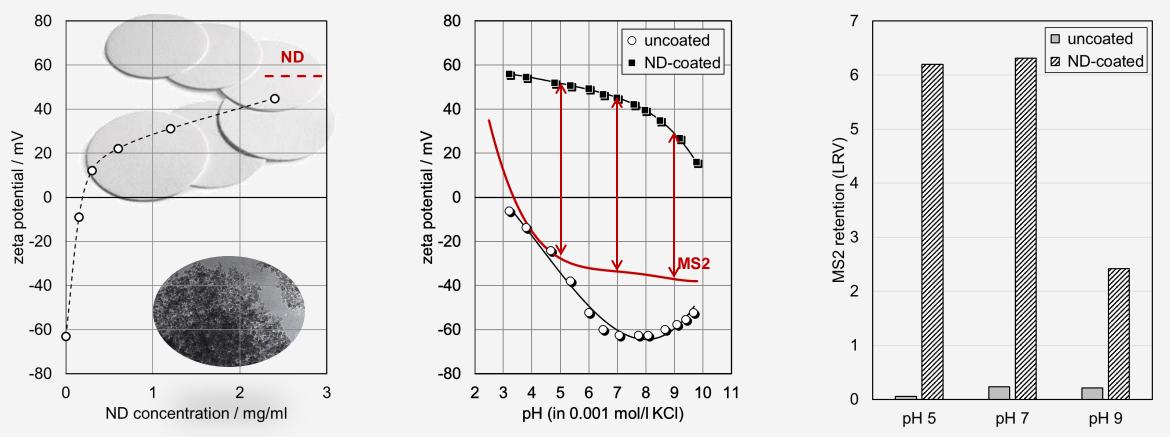






## Nanodiamond meets quartz filter

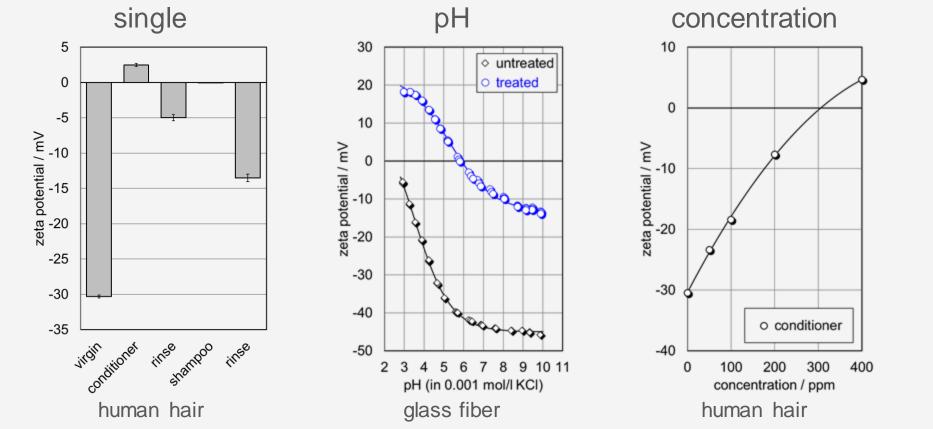
ND-coated quartz filter for virus retention

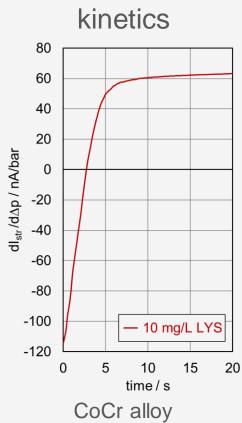


Bland et al., ACS Appl. Nano Mater. 4 (2021) 3252



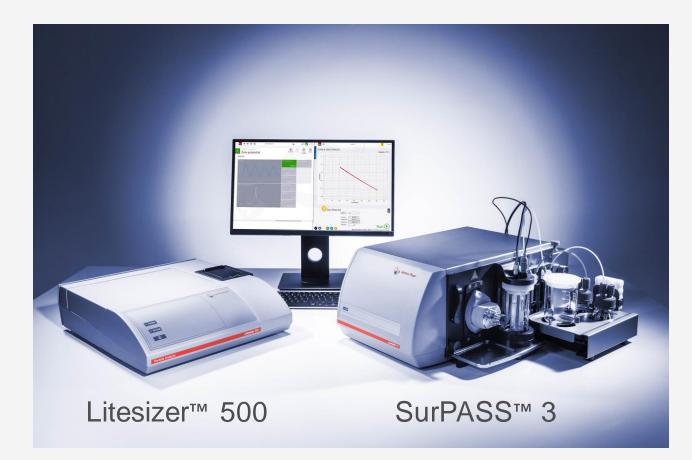
## **Summary**







## Thank you for your attention!





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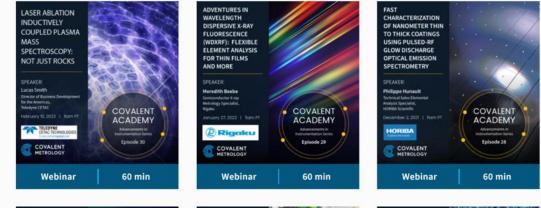
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PEAKER: anette remwattananon, PhD micr Manager, Material sporty Testing clother 7: 2021   IIAM IFT	COVALENT





Q & A Session



# COVALENT METROLOGY

**Thank You**